



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: De et al.

Serial No. 10/699,298

Title: NOVEL COPOLYMER, PHOTORESIST COMPOSITIONS THEREOF
AND DEEP UV BILAYER SYSTEM THEREOF

Filed: October 31, 2003

Examiner: Christopher M. Keehan

Art Unit: 1712

Confirmation No.: 5394

Customer No. : 27,623

Attorney Docket No.: 335.7735USU

Mail Stop: AMENDMENT
Commissioner For Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE TO OFFICE ACTION OF SEPT. 27, 2004

Honorable Commissioner for Patents:

The amended claims in this application are as set forth in the next section of this Response.
The claims are allowable for the reasons set forth in the Remarks section of this Response.